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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/617,487	07/11/2003	C. Andre T. Salama	SALA:003	2844	
7590 12/17/2004			EXAMINER		
ROSSI & ASSOCIATES			LEWIS, MONICA		
P.O. Box Ashburn, VA 20146-0826			ART UNIT	PAPER NUMBER	
,			2822		
			DATE MAILED: 12/17/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

		A	pplication No.	Applicant(s)				
Office Action Summary			0/617,487	SALAMA ET AL.				
			xaminer	Art Unit				
			onica Lewis	2822				
Period fo	The MAILING DATE of this communi or Reply	cation appear	s on the cover sheet with	the correspondence ac	ddress			
THE - Exte after - If the - If NC - Failt Any	ORTENED STATUTORY PERIOD FO MAILING DATE OF THIS COMMUNIO nsions of time may be available under the provisions of SIX (6) MONTHS from the mailing date of this comme of period for reply specified above is less than thirty (30 period for reply is specified above, the maximum stature to reply within the set or extended period for reply veryly received by the Office later than three months af ed patent term adjustment. See 37 CFR 1.704(b).	CATION. of 37 CFR 1.136(a) unication. of days, a reply with tutory period will ap will, by statute, cau	. In no event, however, may a repl nin the statutory minimum of thirty (oply and will expire SIX (6) MONTH se the application to become ABAN	y be timely filed 30) days will be considered time IS from the mailing date of this of IDONED (35 U.S.C. § 133).				
Status								
1)	Responsive to communication(s) filed	d on <u>11 July 2</u>	<u>2003</u> .					
2a)□	This action is FINAL . 2	b)⊠ This act	tion is non-final.					
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the ments is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposit	ion of Claims							
5)□	Claim(s) 1-10 is/are pending in the appearance of the above claim(s) is/are Claim(s) is/are allowed. Claim(s) 1-10 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restrict	e withdrawn f						
Applicat	ion Papers							
9)	The specification is objected to by the	Examiner.						
10)🖂	D)⊠ The drawing(s) filed on <u>03 February 2004</u> is/are: a)□ accepted or b)⊠ objected to by the Examiner.							
	Applicant may not request that any object			• •				
11)	Replacement drawing sheet(s) including The oath or declaration is objected to			•	• •			
Priority ι	ınder 35 U.S.C. § 119							
a)l	Acknowledgment is made of a claim for All b) Some * c) None of: 1. Certified copies of the priority of None of: 2. Certified copies of the priority of None of: 3. Copies of the certified copies of the priority of None of the priority of None of the priority of None of the Certified copies of the certified copies of None o	documents had documents had fithe priority on the priority on the priority of the pure the priority of the pure	ave been received. ave been received in App documents have been re CT Rule 17.2(a)).	olication No ceived in this National	Stage			
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	e of References Cited (PTO-892)	20.046	4) Interview Sum					
3) 🛛 Inforr	e of Draftsperson's Patent Drawing Review (PT nation Disclosure Statement(s) (PTO-1449 or F r No(s)/Mail Date <u>2/04</u> .			Aail Date rmal Patent Application (PTC	O-152)			

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DETAILED ACTION

1. This office action is in response to the application filed July 11, 2003.

Drawings

2. The drawings are objected to as failing to comply with 37 CFR 1.84(p)(5) because they include the following reference character(s) not mentioned in the description: a) 26 (See Figure 2). Corrected drawing sheets in compliance with 37 CFR 1.121(d), or amendment to the specification to add the reference character(s) in the description in compliance with 37 CFR 1.121(b) are required in reply to the Office action to avoid abandonment of the application. Any amended replacement drawing sheet should include all of the figures appearing on the immediate prior version of the sheet, even if only one figure is being amended. The replacement sheet(s) should be labeled "Replacement Sheet" in the page header (as per 37 CFR 1.84(c)) so as not to obstruct any portion of the drawing figures. If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

Specification

3. The specification is objected to as failing to provide proper antecedent basis for the claimed subject matter (See Claims 8 and 9). See 37 CFR 1.75(d)(1) and MPEP § 608.01(o). Correction is required.

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Claim Rejections - 35 USC § 112

4. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

5. Claims 2-10 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. It is not clear what is meant by the following: a) the product of the doping concentration of the reduced surface field portion and the vertical thickness of the reduced surface field portion is about 2 x 10¹² (See Claim 8); and b) the product of the doping concentration of the super junction pillars and a transverse pillar width is about 2 x 10¹² (See Claim 9). It is not clear how the concentration and the thickness are both 2 x 10¹² (See Claim 8). Additionally, it is not clear how the concentration and the width are both 2 x 10¹² (See Claim 9). Finally, there are no metric units. For example, is it cm³ or um.

Claim Rejections - 35 USC § 103

- 6. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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7. Claims 1-7 are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Prior Art in view of Kitagawa et al. (U.S. Patent No. 6,777,746).

In regards to claim 1, Applicant's Prior Art discloses the following:

- a) a substrate (22) (For Example: See Figure 2);
- b) an epitaxial layer (24) formed on the substrate (For Example: See Figure 2);
- c) a well region (28) formed in the epitaxial layer (For Example: See Figure 2);
- d) a source region formed in the well region (For Example: See Figure 2);
- e) a drain region formed in the epitaxial layer (For Example: See Figure 2); and
- f) a gate region located above at least a portion of the well region (For Example: See Figure 2).

In regards to claim 1, Applicant's Prior Art fails to disclose the following:

a) a split-drift region located between the source region and drain region.

However, Kitagawa et al. ("Kitagawa") discloses the use of a split-drift region (12 and 13) located between the source region (8) and drain region (10) (For Example: See Figure 4). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Applicant's Prior Art to include the use of a split-drift region located between the source region and drain region as disclosed in Kitagawa because it aids in providing a device with a low on state resistance (For Example: See Column 2 Lines 14-20).

Additionally, since Applicant's Prior Art and Kitagawa are both from the same field of endeavor, the purpose disclosed by Kitagawa would have been recognized in the pertinent art of Applicant's Prior Art.

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In regards to claim 2, Applicant's Prior Art fails to disclose the following:

a) the split-drift region comprises a super junction portion and a reduced surface field portion.

However, Kitagawa discloses the use of a split-drift region that comprises a super junction portion and a reduced surface field portion (For Example: See Column 1 Lines 51-55 and Figure 4). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Applicant's Prior Art to include the use of a split-drift region that comprises a super junction portion and a reduced surface field portion as disclosed in Kitagawa because it aids in providing a device with a low on state resistance (For Example: See Column 2 Lines 14-20).

Additionally, since Applicant's Prior Art and Kitagawa are both from the same field of endeavor, the purpose disclosed by Kitagawa would have been recognized in the pertinent art of Applicant's Prior Art.

In regards to claim 3, Applicant's Prior Art fails to disclose the following:

a) the super junction portion is positioned adjacent to the well region.

However, Kitagawa discloses the use of the super junction portion positioned adjacent to the well region (For Example: See Column 1 Lines 51-55 and Figure 4). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Applicant's Prior Art to include the use of a super junction portion positioned adjacent to the well region as disclosed in Kitagawa because it aids in providing a device with a low on state resistance (For Example: See Column 2 Lines 14-20).

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Additionally, since Applicant's Prior Art and Kitagawa are both from the same field of endeavor, the purpose disclosed by Kitagawa would have been recognized in the pertinent art of Applicant's Prior Art.

In regards to claim 4, Applicant's Prior Art fails to disclose the following:

a) the super junction portion comprises alternately arranged pillars of first and second conductivity types.

However, Kitagawa discloses the use of a super junction portion that comprises alternately arranged pillars of first and second conductivity types (For Example: See Figure 4). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Applicant's Prior Art to include the use of a super junction portion that comprises alternately arranged pillars of first and second conductivity types as disclosed in Kitagawa because it aids in providing a device with a low on state resistance (For Example: See Column 2 Lines 14-20).

Additionally, since Applicant's Prior Art and Kitagawa are both from the same field of endeavor, the purpose disclosed by Kitagawa would have been recognized in the pertinent art of Applicant's Prior Art.

In regards to claim 5, Applicant's Prior Art fails to disclose the following:

a) the reduced surface field portion is located adjacent to the drain region.

However, Kitagawa discloses the reduced surface field portion is located adjacent to the drain region (For Example: See Figure 4). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Applicant's Prior Art to include Kitagawa discloses the reduced surface field portion is located adjacent to

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• the drain region as disclosed in Kitagawa because it aids in providing a device with a low on state resistance (For Example: See Column 2 Lines 14-20).

Additionally, since Applicant's Prior Art and Kitagawa are both from the same field of endeavor, the purpose disclosed by Kitagawa would have been recognized in the pertinent art of Applicant's Prior Art.

In regards to claim 6, Applicant's Prior Art fails to disclose the following:

a) the reduced surface field portion comprises a first conductivity type and the substrate comprises a second conductivity type.

However, Kitagawa discloses the reduced surface field portion comprises a first conductivity type and the substrate (1) comprises a second conductivity type (For Example: See Figure 4). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Applicant's Prior Art to include Kitagawa discloses that the reduced surface field portion comprises a first conductivity type and the substrate comprises a second conductivity type as disclosed in Kitagawa because it aids in providing a device with a low on state resistance (For Example: See Column 2 Lines 14-20).

Additionally, since Applicant's Prior Art and Kitagawa are both from the same field of endeavor, the purpose disclosed by Kitagawa would have been recognized in the pertinent art of Applicant's Prior Art.

In regards to claim 7, Applicant's Prior Art fails to disclose the following:

a) the length of the reduced surface field portion is much less than the length of the super junction portion.

However, the applicant has not established the critical nature of the length of the reduced surface field portion is much less than the length of the super junction portion. "The law is

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replete with cases in which the difference between the claimed invention and the prior art is some range or other variable within the claims. . . . In such a situation, the applicant must show that the particular range is critical, generally by showing that the claimed range achieves unexpected results relative to the prior art range." *In re Woodruff*, 919 F.2d 1575, 16 USPQ2d 1934 (Fed. Cir.1990). Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to have various ranges.

8. Claims 8 and 9, as far as understood, are rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Prior Art in view of Kitagawa et al. (U.S. Patent No. 6,777,746) and Kawaguchi et al. (U.S. Patent No. 6,297,534).

In regards to claim 8, Applicant's Prior Art fails to disclose the following:

a) the product of the doping concentration of the reduced surface field portion and the vertical thickness of the reduced surface field portion is about 2×10^{12} .

However, Kawaguchi et al. ("Kawaguchi") discloses the product of the doping concentration is 1.0×10^{17} cm⁻³ (For Example: See Column 6 Lines 53-65). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Applicant's Prior Art to include Kawaguchi discloses that the product of the doping concentration is 1.0×10^{17} cm⁻³ as disclosed in Kawaguchi because it aids in providing a device with a low on resistance (For Example: See Column 2 Lines 1 and 2).

Additionally, since Applicant's Prior Art and Kawaguchi are both from the same field of endeavor, the purpose disclosed by Kawaguchi would have been recognized in the pertinent art of Applicant's Prior Art.

Finally, the applicant has not established the critical nature of the product of the doping concentration of the reduced surface field portion and the vertical thickness of the reduced

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ranges.

surface field portion is about 2 x 10¹². "The law is replete with cases in which the difference between the claimed invention and the prior art is some range or other variable within the claims.

... In such a situation, the applicant must show that the particular range is critical, generally by showing that the claimed range achieves unexpected results relative to the prior art range." *In re Woodruff*, 919 F.2d 1575, 16 USPQ2d 1934 (Fed. Cir.1990). Therefore, it would have been

obvious to one having ordinary skill in the art at the time the invention was made to have various

In regards to claim 9, Applicant's Prior Art fails to disclose the following:

a) the product of the doping concentration of the super junction pillars and a transverse pillar width is about 2×10^{12} .

However, Kawaguchi et al. discloses the product of the doping concentration is $1.0x10^{17}$ cm⁻³ (For Example: See Column 6 Lines 53-65). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Applicant's Prior Art to include Kawaguchi discloses that the product of the doping concentration is $1.0x10^{17}$ cm⁻³ as disclosed in Kawaguchi because it aids in providing a device with a low on resistance (For Example: See Column 2 Lines 1 and 2).

Additionally, since Applicant's Prior Art and Kawaguchi are both from the same field of endeavor, the purpose disclosed by Kawaguchi would have been recognized in the pertinent art of Applicant's Prior Art.

Finally, the applicant has not established the critical nature of the product of the doping concentration of the super junction pillars and a transverse pillar width is about 2×10^{12} . "The law is replete with cases in which the difference between the claimed invention and the prior art is some range or other variable within the claims. . . . In such a situation, the applicant must show

that the particular range is critical, generally by showing that the claimed range achieves unexpected results relative to the prior art range." *In re Woodruff*, 919 F.2d 1575, 16 USPQ2d 1934 (Fed. Cir.1990). Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to have various ranges.

9. Claim 10 is rejected under 35 U.S.C. 103(a) as being unpatentable over Applicant's Prior Art in view of Kitagawa et al. (U.S. Patent No. 6,777,746) and Disney et al. (U.S. Patent No. 6,815,293).

In regards to claim 10, Applicant's Prior Art fails to disclose the following:

a) an oxide layer formed over the split-drift region.

However, Kitagawa discloses the use of an oxide layer over a split-drift region (For Example: See Column 5 Lines 25-30). It would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the semiconductor of Applicant's Prior Art to include the use of an oxide layer over a split-drift region as disclosed in Kitagawa because it aids in providing a device with a low on state resistance (For Example: See Column 2 Lines 14-20).

Additionally, since Applicant's Prior Art and Kitagawa are both from the same field of endeavor, the purpose disclosed by Kitagawa would have been recognized in the pertinent art of Applicant's Prior Art.

b) metal field plates formed on portions of the oxide layer adjacent to the gate region and the drain region.

However, Disney et al. ("Disney") discloses the use of a metal field plate (164) formed on an oxide layer (169) adjacent to the gate (75) and drain (For Example: See Figure 7c). It would have been obvious to one having ordinary skill in the art at the time the invention was

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made to modify the semiconductor of Applicant's Prior Art to include the use of metal field plate formed on an oxide layer adjacent to the gate and drain as disclosed in Disney because it aids in providing a device that can withstand high voltages (For Example: See Column 1 Lines 15-20).

Additionally, since Applicant's Prior Art and Disney are both from the same field of endeavor, the purpose disclosed by Disney would have been recognized in the pertinent art of Applicant's Prior Art.

Conclusion

- 10. The following prior art made of record and not relied upon is considered pertinent to applicant's disclosure: a) Yamaguchi et al. (U.S. Publication No. 2003/0222327) discloses a semiconductor device; b) Yamauchi et al. (U.S. Publication No. 2003/0219933) discloses a semiconductor device having an epitaxially filled trench; c) Parthasarathy et al. (U.S. Publication No. 2003/0214009) discloses a resurf super junction device device; d) Onishi et al. (U.S. Publication No. 2004/02112032) discloses a lateral super junction device; e) Onishi et al. (U.S. Patent No. 6,756,636) discloses a lateral super junction device; and f) Kitagawa et al. (U.S. Publication No. 2004/0232483) discloses a field effect transistor.
- Any inquiry concerning this communication or earlier communications from the examiner should be directed to Monica Lewis whose telephone number is 571-272-1838.

 If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on 571-272-1852. The fax phone number for the organization where this application or proceeding is assigned is 703-308-7722 for regular and after final

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communications. Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956

ML

December 2, 2004

Mary Wilczewski Primary Examiner